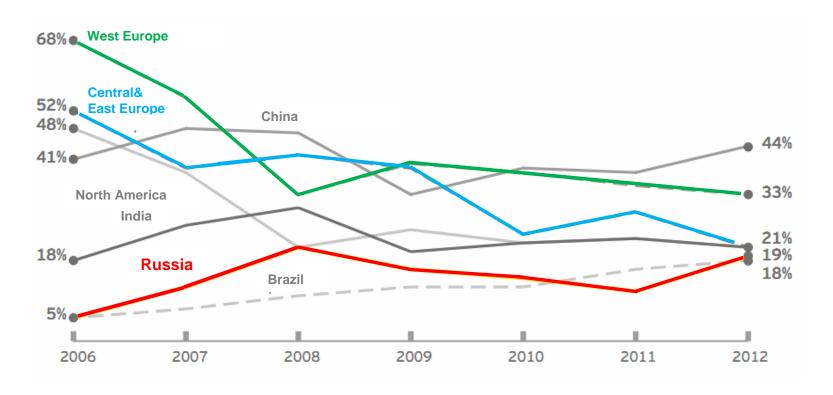


Cross-region investment EU-RUSSIA: RUSNANO experience

Prof. Sergey Kalyuzhnyi, Chief Scientist, Member of the Executive Board



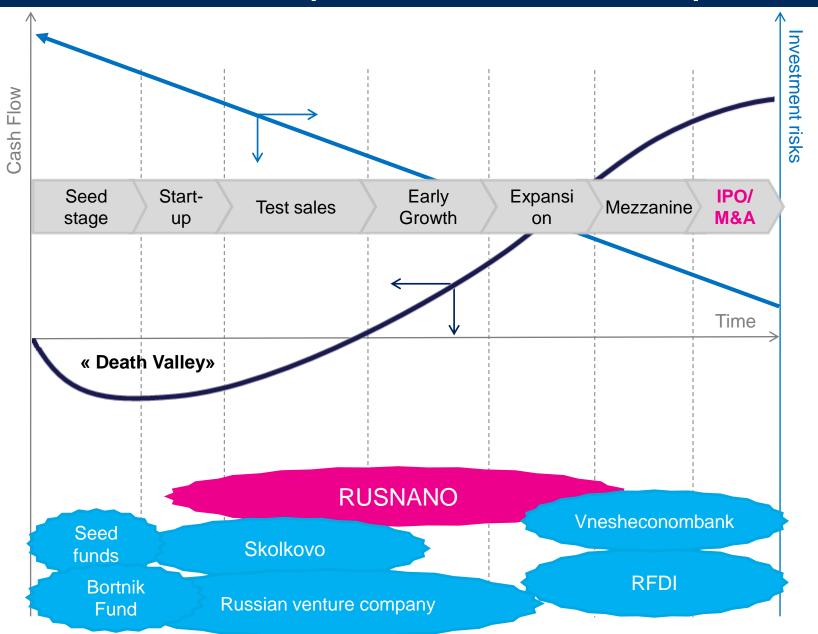
Regions most attractive for investors in order to start business activity



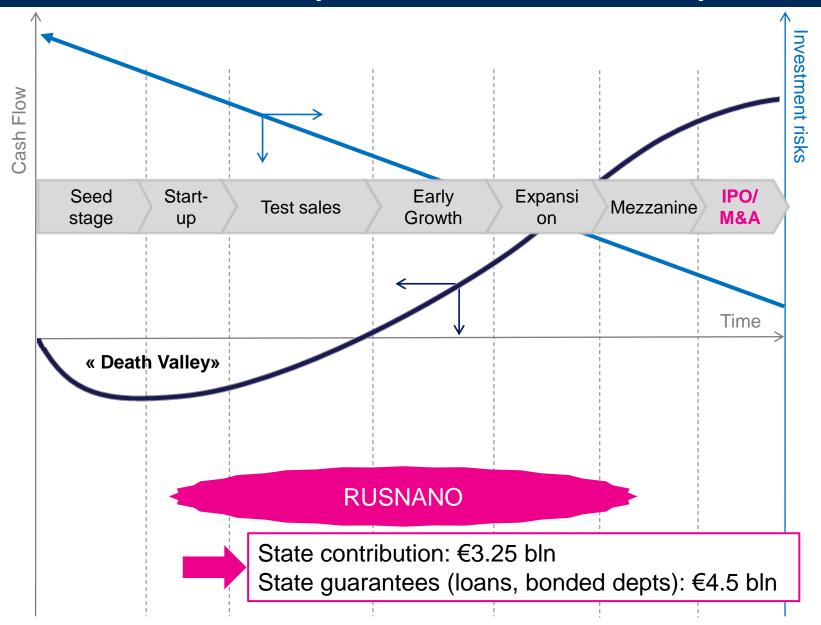
Total foreign investments into Russia (2012) – €116 bln

Total Russian investments abroad (2012) – €112 bln

Russian Development Institutions Landscape



Russian Development Institutions Landscape



RUSNANO and Russian nanoindustry



- Institutes and universities



Independent «nano-companies»

RUSNANO Group of Companies



Project companies

Venture funds

Nanocenters & incubators

RUSNANO holding

Stock Company RUSNANO

Non-profit foundations (educational programs, conferences, infrastructure)

RUSNANO subsidiaries

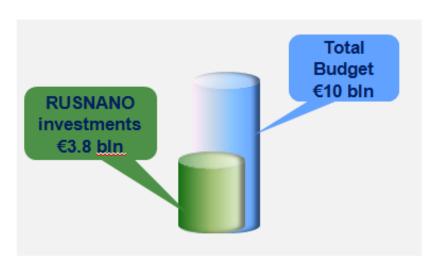
Metrological Center RUSNANO-Inform

RUSNANO USA, Inc.

RUSNANO Israel Ltd.

RUSNANO Capital AG

RUSNANO's Project Portfolio*



INVESTMENT PROJECTS BEING FINANCED 90

CONSOLIDATED REVENUE OF PORTFOLIO COMPANIES (forecast 2015) €2.5 bln



6

RUSNANO Investment Strategy



RUSNANO financing options

Financing options	Investment in Owner's Equity	■ RUSNANO's share couldn't exceed 50% -1 share (on the project's initial stage)
	Debt Finance	■ Various forms of debt finance (loans, credit guarantees, and leasing operations)
Co-Investors		 Companies (by any form of property) Private Persons Financial Institutions Private Equity & Venture Capital Funds
Exit in 4-6 years		 Merger & Acquisition (M&A) Initial Public Offering (IPO) Management or co-investor buyout

Russia & World

Advantages:

- big territory
- rich in energy sources & raw materials
- stable political situation
- low state debt & budget deficit



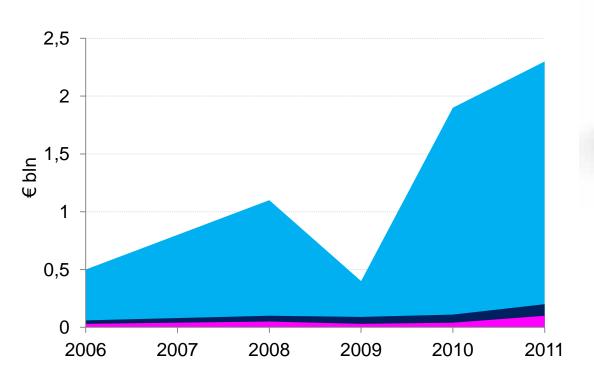




Russian weak points:

- Unbalanced export > 70% for fuel & energy
- Unbalanced import ~ 45% for machinery & transportation facilities
- Relatively low expenses for R&D 1.16% of GDP2010
- Relatively low impact into world knowledge bank
 - Publications 1.5% of world total
 - Patent activity (per 10,000 population) ~ 2

Structure of general RF investment by stage



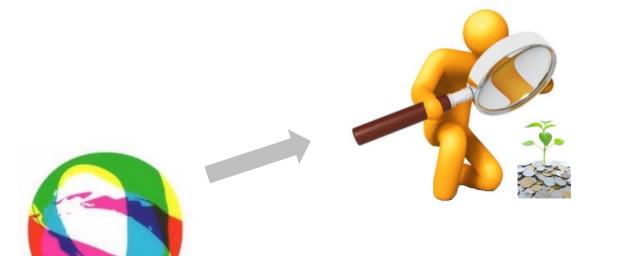






- Expansion and later stages
- Early states
- Seed Investment

RUSNANO investment trends

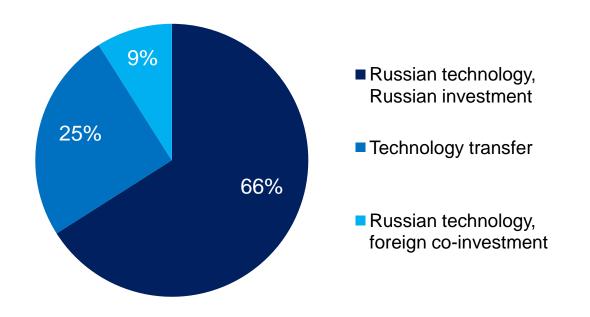


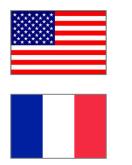
Venture investment



Technology transfer

Projects with foreign participation in RUSNANO portfolio













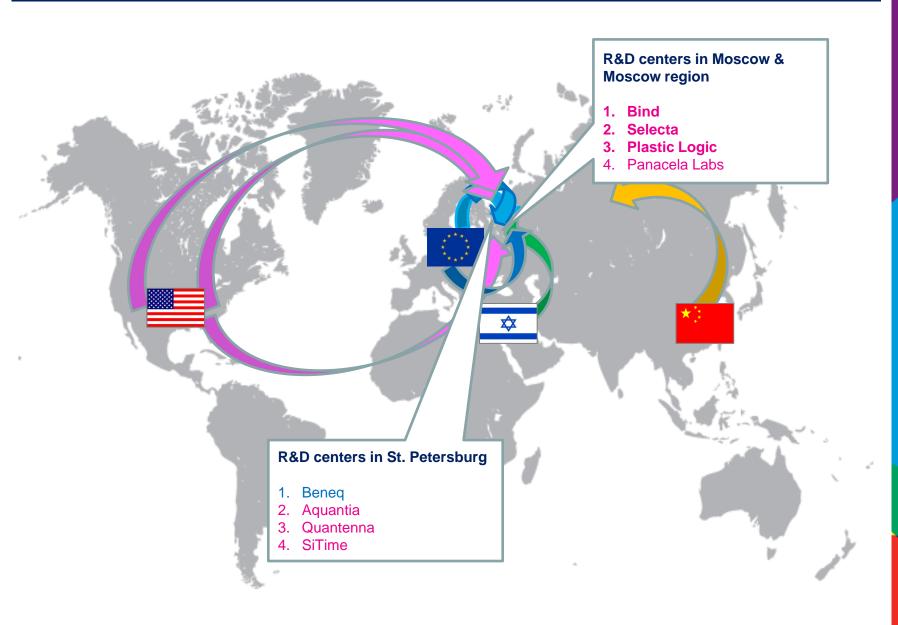








Technologies from worldwide into Russia



Examples of R&D centers (I)

Project Company:

Beneq Oy



Project Goal: Development atomic layer deposition (ALD) and aerosol thin film coating, nAERO[®] and nHALO[®], for highend R&D and demanding industrial environments.

Country of the technology origin: Finland

R&D center: St. Petersburg

RUSNANO Investment: €25 mln



Examples of R&D centers (II)

Project Company:

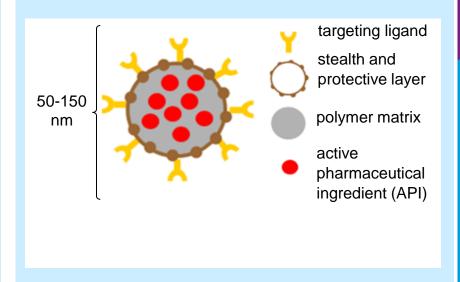
BIND Biosciences Inc.,



Project Goal: Development and commercialization of a new class of **highly selective targeted therapeutics** based on BIND Therapeutics's Accurins™ nanoplatform

R&D center: Moscow

RUSNANO Investment: €19 mln



Examples of R&D centers (III)

Project Company:

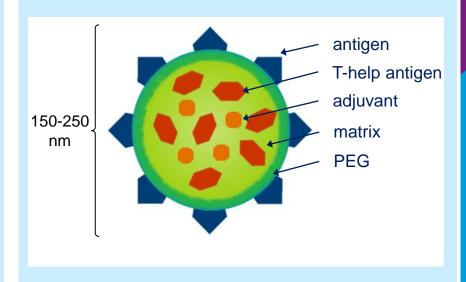
Selecta Biosciences Inc.



Project Goal: Development and commercialization of an entirely new class of **targeted vaccines** that induce antigen-specific immune activation or antigen-specific immune tolerance for therapeutic and prophylactic applications

R&D center: Moscow

RUSNANO Investment: €19 mln



Plants in Russia with foreign participation



Total: 13 plants

New production plants (I)

Project Company:

Optogan



Project Goal: Production of ultrabright nanoheterostructured **LEDs and LED-based lighting systems**

Country of the technology origin:

Russia, Germany, Finland

Location: St. Petersburg

RUSNANO investment: €57 mln



New production plants (II)

Project Company:

Pilkington Group Ltd.

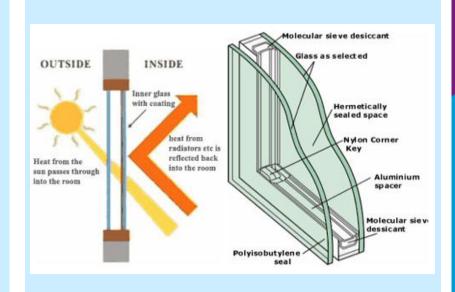


Project Goal: Technology of mass production of energy-efficient glass (low emissivity and solar control glass)

Country of the technology origin: UK

Location: Moscow region & Ulyanovsk

RUSNANO investment: €185 mln



New production plants (III)

Project Company:

MAPPER Lithography B.V. (Spin-off Delft University of Technology)

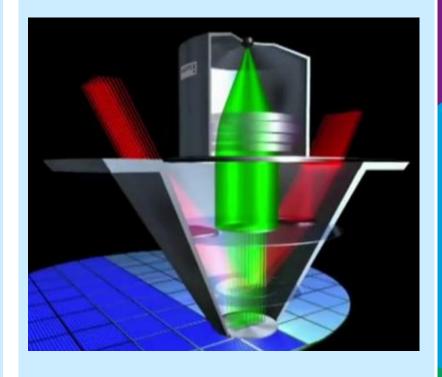


Project Goal: Development of new generation lithography tools (22 nm) based on principals of EB lithography for high-volume manufacturing

Country of the technology origin: Netherlands

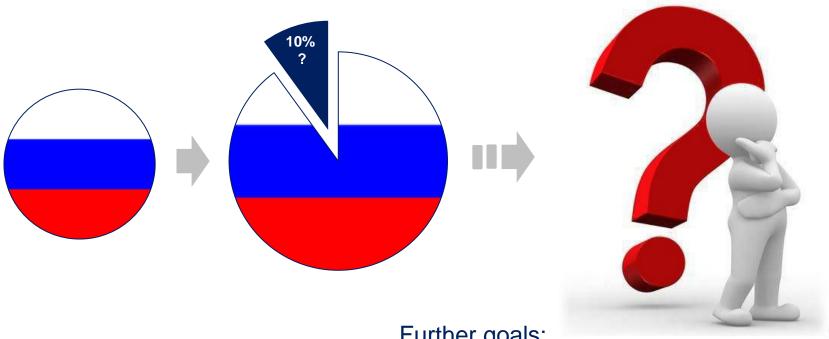
Location: St. Petersburg

Rusnano Investment: €40 mln



RUSNANO on the way to the global technology investment fund

2013: Plans to sell 10% of RUSNANO by private placement



Further goals:

- international cooperation
- attracting private investments
- ✓ further transformation etc.

